

650V SuperGaN™ FET in TO-247 (source tab)

Description

The TP65H015G5WS 650V, 15 m Ω gallium nitride GaN FET is a normally-off device using Transphorm's Gen V platform. It combines a state-of-the-art high voltage GaN HEMT with a low voltage silicon MOSFET to offer superior reliability and performance.

The Gen V SuperGaN™ platform uses advanced epi and patented design technologies to simplify manufacturability while improving efficiency over silicon via lower gate charge, output capacitance, crossover loss, and reverse recovery charge.

Related Literature

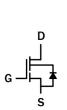
- ANOOO9: Recommended External Circuitry for GaN FETs
- ANOOO3: Printed Circuit Board Layout and Probing
- ANOO10: Paralleling GaN FETs

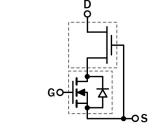
Ordering Information

Part Number	Package	Package Configuration
TP65H015G5WS	3 lead TO-247	Source

TP65H015G5WS T0-247 (top view)







Cascode Schematic Symbol

Cascode Device Structure

Features

- JEDEC qualified GaN technology
- Dynamic R_{DS(on)eff} production tested
- Robust design, defined by
 - Intrinsic lifetime tests
 - Wide gate safety margin
 - Transient over-voltage capability
- Very low Q_{RR}
- Reduced crossover loss

Benefits

- Enables AC-DC bridgeless totem-pole PFC designs
 - Increased power density
 - Reduced system size and weight
 - Overall lower system cost
- Achieves increased efficiency in both hard- and softswitched circuits
- · Easy to drive with commonly-used gate drivers
- GSD pin layout improves high speed design

Applications

- Datacom
- Broad industrial
- PV inverter
- · Servo motor







Key Specifications		
V _{DSS} (V)	650	
V _{(TR)DSS} (V)	725	
$R_{DS(on)eff}(m\Omega)\;max$ *	18	
Q _{RR} (nC) typ	430	
Q _G (nC) typ	74	

^{*} Dynamic on-resistance; see Figures 18 and 19

Absolute Maximum Ratings (T_c=25 °C unless otherwise stated.)

Symbol	Parameter		Limit Value	Unit
V _{DSS}	Drain to source voltage (T _J = -	55°C to 150°C)	650	
V _{(TR)DSS}	Transient drain to source voltage a		725	V
V _{GSS}	Gate to source voltage		±20	
P _D	Maximum power dissipation @	um power dissipation @Tc=25°C		W
I _D	Continuous drain current @T _C =25°C b		93	A
ID	Continuous drain current @T _C =100°C b		59	A
I _{DM}	Pulsed drain current (pulse wi	Pulsed drain current (pulse width: 10µs)		A
T _C	Operating temperature	Case	-55 to +150	°C
TJ	Operating temperature	Junction	-55 to +150	°C
T _S	Storage temperature		-55 to +150	°C
Tsold	Soldering peak temperature ^c		260	°C

Notes:

- a. In off-state, spike duty cycle D<0.01, spike duration <1µs
- b. For increased stability at high current operation, see Circuit Implementation on page 3
- c. For 10 sec., 1.6mm from the case

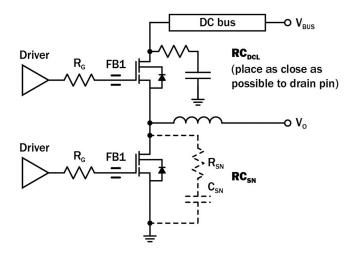
Thermal Resistance

Symbol	Parameter	Typical	Unit
Rejc	Junction-to-case	0.47	°C/W
R _{OJA}	Junction-to-ambient	40	°C/W

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Circuit Implementation



Layout Recommendations: (See also ANOOO9) Gate Loop:

- Gate Driver: SiLab Si823x/Si827x
- Keep gate loop compact
- Minimize coupling with power loop

Power loop: (For reference see page 13)

- Minimize power loop path inductance
- Minimize switching node coupling with high and low power plane
- Add DC bus snubber to reduce to voltage ringing
- Add Switching node snubber for high current operation

Simplified Half-bridge Schematic (See also on Figure 13)

Recommended gate drive: (OV, 12V) with R_G=15 Ω

Gate Ferrite Bead (FB1)	Required DC Link RC Snubber (RC _{DCL}) ^a	Recommended Switching Node RC Snubber (RC _{SN}) ^{b,c}
80-120 Ω at 100MHz	[10nF + 3.3 Ω] x 3	Not necessary

Notes:

- a. RC_DCL should be placed as close as possible to the drain pin
- $b. \quad RC_{SN} \ \text{is needed only if } R_G \ \ \text{is smaller than recommendations or operational current exceeds 100C rated } I_{DMAX}$
- c. If required, please use (100 pF + 10 ohm) or parallel two or three of the same

Electrical Parameters (T_J=25 °C unless otherwise stated)

Symbol	l Parameter		Тур	Max	Unit	Test Conditions	
Forward Device Characteristics							
$V_{(BL)DSS}$	Drain-source voltage	650	_	_	V	V _{GS} =0V	
$V_{\text{GS(th)}}$	Gate threshold voltage	3.3	4	4.8	V	V _{DS} =V _{GS} , I _D =2mA	
D	Drain-source on-resistance a	_	15	18	mO	V _{GS} =10V, I _D =60A	
R _{DS(on)eff}	Diam-source off-resistance	_	31	_	- mΩ	V _{GS} =10V, I _D =60A, T _J =150°C	
	Drain to course leakage current	_	7	70		V _{DS} =650V, V _{GS} =0V	
I _{DSS}	Drain-to-source leakage current	_	50	_	- μA	V _{DS} =650V, V _{GS} =0V, T _J =150°C	
	Gate-to-source forward leakage current	_	_	400	0	V _{GS} =20V	
I_{GSS}	Gate-to-source reverse leakage current	_	_	-400	- nA	V _{GS} =-20V	
C _{ISS}	Input capacitance	_	5218	_		V _{GS} =0V, V _{DS} =400V, <i>f</i> =1MHz	
Coss	Output capacitance	_	307	_	pF		
C_{RSS}	Reverse transfer capacitance	_	26	_			
$C_{\text{O(er)}}$	Output capacitance, energy related b	_	476	_	pF	V _{GS} =0V, V _{DS} =0V to 400V	
$C_{O(tr)}$	Output capacitance, time related °	_	1026	_	Pi		
Q_{G}	Total gate charge	_	74	100		V _{DS} =400V, V _{GS} =0V to 10V, I _D =60A	
Q_{GS}	Gate-source charge	_	34	_	nC		
Q_{GD}	Gate-drain charge	_	21	_			
Qoss	Output charge	_	430	_	nC	V _{GS} =0V, V _{DS} =0V to 400V	
t _{D(on)}	Turn-on delay	_	87	_		$\begin{array}{c} V_{DS}{=}400V,V_{GS}{=}0Vto12V,\\ R_{G}{=}15\Omega,Z_{FB}{=}120\Omegaat100MHz,\\ I_{D}{=}60A \end{array}$	
t _R	Rise time	_	18	_	ns		
$t_{\text{D(off)}}$	Turn-off delay	_	123	_			
t _F	Fall time	_	9.4	_			

Notes:

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a. Dynamic on-resistance; see Figures 18 and 19 for test circuit and conditions

b. Equivalent capacitance to give same stored energy as V_{DS} rises from 0V to 400V

c. Equivalent capacitance to give same charging time as V_{DS} rises from 0V to 400V

Electrical Parameters (T_J=25 °C unless otherwise stated)

Symbol	Parameter	Min	Тур	Max	Unit	Test Conditions	
Reverse Dev	Reverse Device Characteristics						
Is	Reverse current	_	_	60	А	V _{GS} =0V, T _C =100°C ≤15% duty cycle	
V	Reverse voltage ^a	_	1.6	_	V	V _{GS} =0V, I _S =60A	
V_{SD}		_	1.2	_		V _{GS} =0V, I _S =30A	
t _{RR}	Reverse recovery time	_	100	_	ns	I _S =60A, V _{DD} =400V, di/dt=1000A/μs	
Q _{RR}	Reverse recovery charge	_	430	_	nC		
(di/dt) _{RM}	Reverse diode di/dt b	_	_	3500	A/µs	Circuit implementation and parameters on page 3	

Notes:

a. Includes dynamic R_{DS(on)} effect

b. Reverse conduction di/dt will not exceed this max value with recommended R_G.

Typical Characteristics (T_C=25 °C unless otherwise stated)

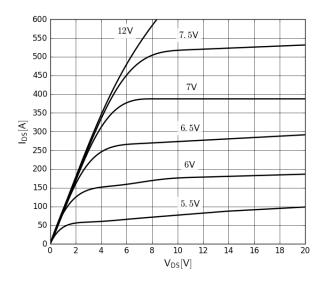


Figure 1. Typical Output Characteristics T_J=25 °C

Parameter: V_{GS}

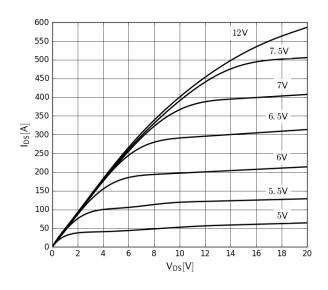


Figure 2. Typical Output Characteristics T_J=150 °C

Parameter: V_{GS}

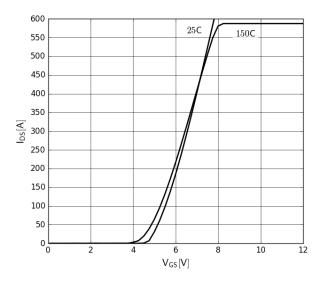


Figure 3. Typical Transfer Characteristics V_{DS} =20V, parameter: T_J

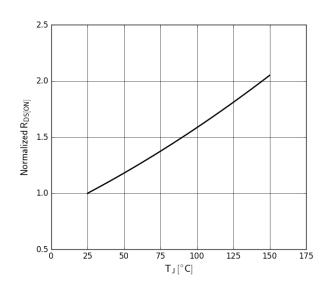
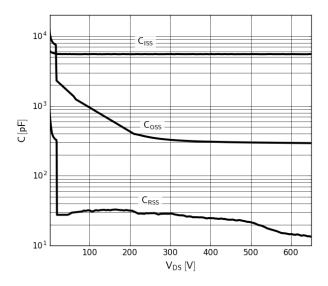


Figure 4. Normalized On-resistance $I_D=60A,\ V_{GS}=8V$

Typical Characteristics (T_C=25 °C unless otherwise stated)



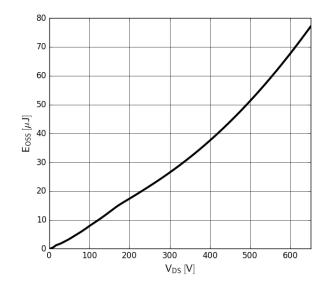
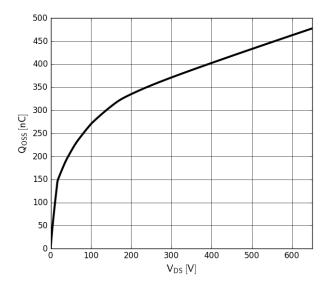


Figure 5. Typical Capacitance V_{GS} =0V, f=1MHz

Figure 6. Typical Coss Stored Energy



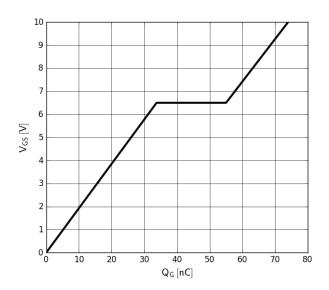
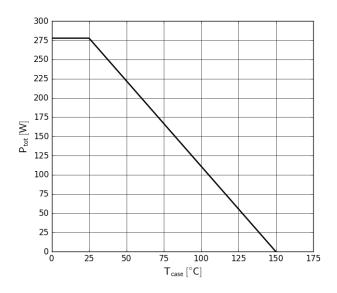


Figure 7. Typical Qoss

Figure 8. Typical Gate Charge I_{DS}=60A, V_{DS}=400V

Typical Characteristics (Tc=25°C unless otherwise stated)



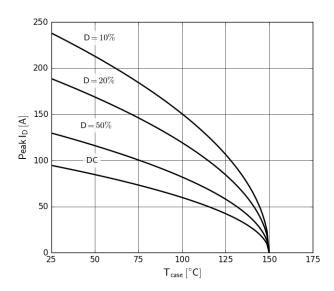


Figure 9. Power Dissipation

Figure 10. Current Derating Pulse width $\leq 10\mu s$, $V_{GS} \geq 10V$

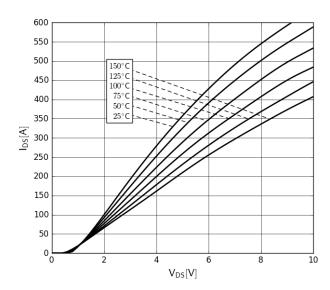


Figure 11. Forward Characteristics of Rev. Diode $I_S {=} f(V_{SD}), \ parameter; \ T_J$

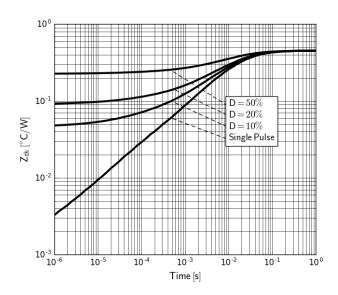


Figure 12. Transient Thermal Resistance

Typical Characteristics (T_C =25 $^{\circ}$ C unless otherwise stated)

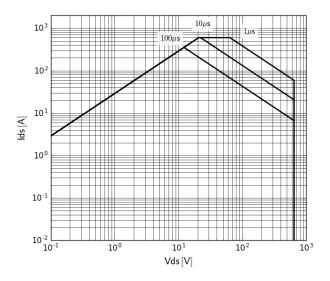


Figure 13. Safe Operating Area T_C=25°C

Test Circuits and Waveforms

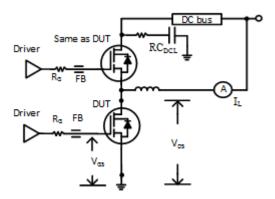


Figure 14. Switching Time Test Circuit (see circuit implementation on page 3 for methods to ensure clean switching)

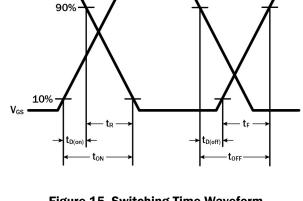


Figure 15. Switching Time Waveform

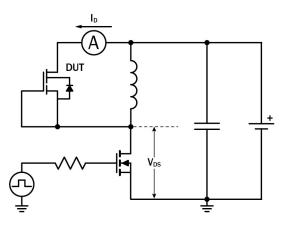


Figure 16. Diode Characteristics Test Circuit

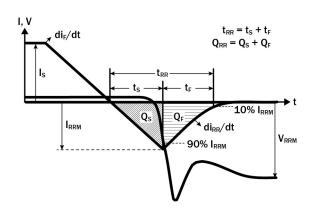


Figure 17. Diode Recovery Waveform

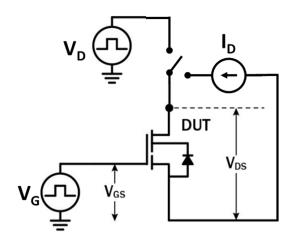


Figure 18. Dynamic R_{DS(on)eff} Test Circuit

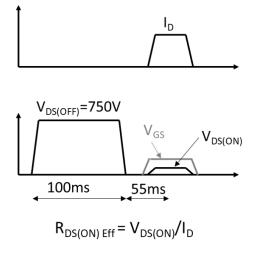


Figure 19. Dynamic R_{DS(on)eff} Waveform

Design Considerations

The fast switching of GaN devices reduces current-voltage crossover losses and enables high frequency operation while simultaneously achieving high efficiency. However, taking full advantage of the fast switching characteristics of GaN switches requires adherence to specific PCB layout guidelines and probing techniques.

Before evaluating Transphorm GaN devices, see application note <u>Printed Circuit Board Layout and Probing for GaN Power Switches</u>. The table below provides some practical rules that should be followed during the evaluation.

When Evaluating Transphorm GaN Devices:

DO	DO NOT
Minimize circuit inductance by keeping traces short, both in the drive and power loop	Twist the pins of T0-220 or T0-247 to accommodate GDS board layout
Minimize lead length of TO-220 and TO-247 package when mounting to the PCB	Use long traces in drive circuit, long lead length of the devices
Use shortest sense loop for probing; attach the probe and its ground connection directly to the test points	Use differential mode probe or probe ground clip with long wire
See AN0003: Printed Circuit Board Layout and Probing	

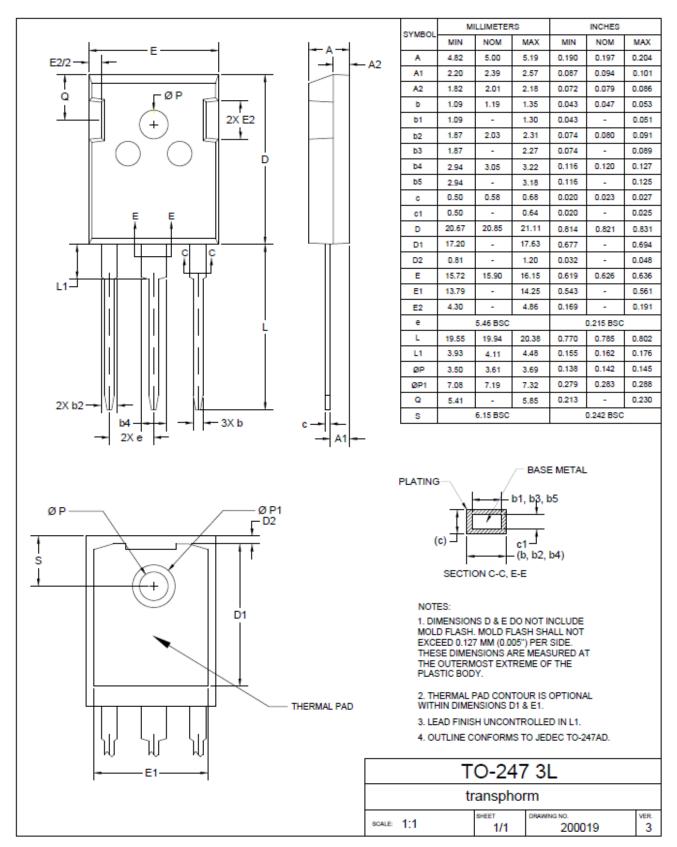
GaN Design Resources

The complete technical library of GaN design tools can be found at transphormusa.com/design:

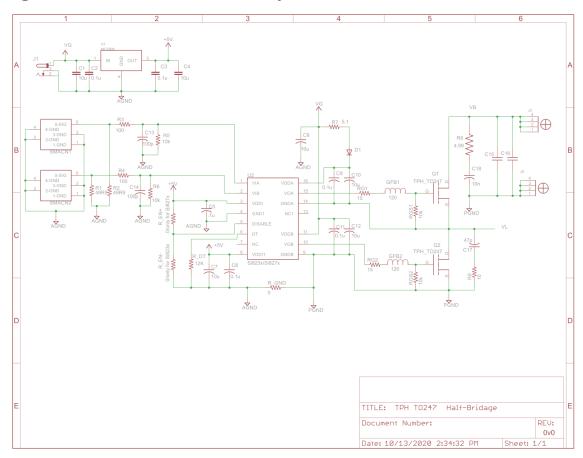
- Evaluation kits
- Application notes
- · Design guides
- · Simulation models
- Technical papers and presentations

Mechanical

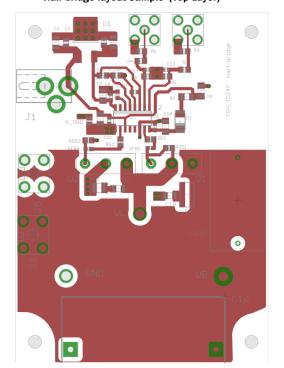
3 Lead TO-247 Package



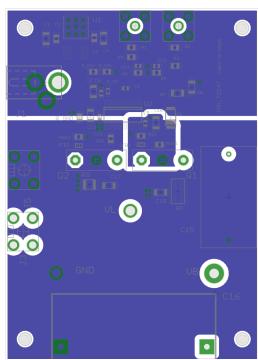
Half-bridge Reference Schematic and PCB Layout



Half-bridge layout Sample (Top Layer)



Half-bridge layout Sample (Bottom Layer)



Revision History

Version	Date	Change(s)	
0.1	5/25/2020	Preliminary Datasheet	
0.2	9/24/2020	Preliminary Datasheet	
0.2	02/23/2021	Preliminary Datasheet. Update Figure 18, 19	
1.0	07/12/2021	Datasheet complete	

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